

BIS (TRIMETHYLSILYL) AMIDE AS NITRILE PRECURSOR

Benoît Rigo*^a, Charles Lespagnol^b and Marc Pauly^c

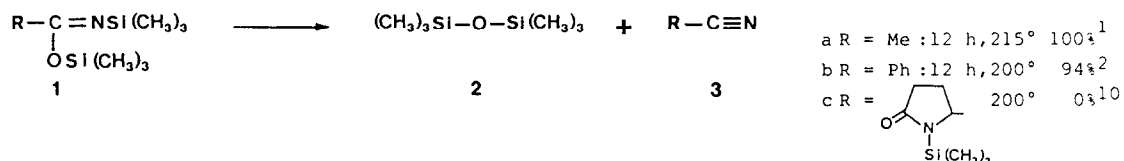
a) Laboratoire de Synthèses Organiques, Ecole des Hautes Etudes Industrielles, 13 Rue de Toul, 59046 Lille, France.

b) Institut de Chimie Pharmaceutique, 3 rue du Professeur Laquesse, 59045 Lille, France.

c) Laboratoires Sérobiologiques, B.P. 670, 54010 Nancy, France.

Abstract : Bis (trimethylsilyl) amides are converted into nitriles with high yields when they are treated with a catalyst (tetrabutylammonium fluoride, Lewis acids or iron phthalocyanine).

Since its discovery, (1962)^{1,2}, the thermal decomposition of bis (trimethylsilyl) amides to nitriles has only been reported in two reviews^{3,4}, and has never been used as a preparative method for nitriles synthesis; recent reviews on silicon chemistry do not report this reaction⁵⁻⁸.



However this thermal reaction is not general and, for instance, compound 1c remains unaltered under these conditions. In this paper we describe the catalytic decomposition of silylated amides :

Catalyst

Three different catalysts promote the decomposition of 1b used as a model compound :

- Tetrabutylammonium fluoride, which is a very soluble form of fluoride ion, can be used in this reaction (20 h ; 15° ; 100%). Less soluble fluoride compounds do not promote the decomposition to nitrile at room temperature.

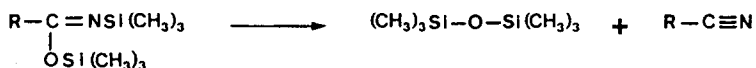
- True Lewis acids such as FeCl₃ (1 h, 15°, 100% ; 40 h, -70°, 50%), ZnCl₂ (10mn, 65°, 100%) or AlCl₃ (2 h, 20°, 95%) are very efficient catalysts.

- Iron phthalocyanine, also catalyses this decomposition at 75° (6 h, 100%). This compound is of special interest because it is the first time that it has been used in siloxane elimination ; cobalt and fluorochromium phthalocyanines are unreactive at 90°.

Scope of the reaction (table I)

As evidenced in the table, this siloxane elimination is general and succeeds in every case, except when R is a strong withdrawing group. Another important feature is that the catalysts are complementary because they do not have the same sensitivity to the structure of the molecule : when iron trichloride is partly deactivated by a basic group, fluoride ions are not deactivated, and when fluoride cannot be used at room temperature, iron trichloride can be utilized.

TABLE I. NITRILE SYNTHESIS BY ELIMINATION OF HEXAMETHYLDISILOXANE



N°	R	Catalyst : nBu ₄ N ⁺ F ⁻ , 3H ₂ O ^a			Catalyst : FeCl ₃ ^a		
		t(hour)	T°C	Yield % ^b	T(hour)	T°C	Yield % ^b
1	C ₆ H ₅ -	20	15	100	1	15	100
2	2-Me ₃ SiOC ₆ H ₄ -	20	90	100 ^{c,d}	0.5	18	100
3	3-Py-	22	20	95	0.5	80	100 ^d
4	nC ₃ H ₇ -	17	19	95	1	19	95
5	CH ₃ - ^e	3	20	75	0.5	20	100
6	Pyro- ^f	3	80	100	5	80	95
7	CF ₃ - ^h	20	55	0	20	55	0

^aDisilylamide : 1g ; catalyst : 0.02g. ^bNMR yield. ^c83.3% of isolated yield of 2-cyanophenol, after distillation, methanol solvolysis and activated carbon treatment. ^dNo reaction at 20°. ^eAldrich. A minute amount (2%) of acetonitrile found in this commercial product is probably the result of this easy hexamethyldisiloxane elimination. ^fCompound 1c.

This two-steps procedure for the dehydration of amides can be effected in one-step without isolation of the bis (trimethylsilyl) amide : for instance heating nicotinamide (6 g) with trimethylchlorosilane (7 ml), triethylamine (30 ml) and zinc chloride (0.6 g) give a triethylamine solution of bis (trimethylsilyl) derivative 1 (R=3-Py) ; when the solvent was evaporated and the residue distilled in-vacuo, nitrile 2 was obtained in 79% yield ; in the same way, compound 3c was obtained in 91% yield in a preparative scale¹⁰. Thus this method can be used as an alternative to other one-step procedures for the preparation of nitriles^{11,12}.

This work significantly extends the scope of nitrile synthesis using silyl amides : only a catalytic amount of an acidic (FeCl₃), basic (F⁻) or neutral (PCFe) compound is necessary to promote this reaction, in contrast to the published decomposition reaction of a monosilylamide by an equimolar amount of an acidic reagent (acid chloride¹³ or thionyl chloride¹⁴).

REFERENCES

- W. Giessler, Ph. D. Thesis, Universität Köln (1962).
- C. Kruger, E.G. Rochow and U. Wannagat, *Chem. Ber.*, **96**, 2138 (1963).
- L. Birkofer and A. Ritter, *Angew. Chem. Int. Ed. Engl.*, **4**, 417 (1965).
- J.F. Klebe, in "Advances in Organic Chemistry", Vol. 8, E.C. Taylor, ed., John Wiley and Sons, Inc., New York, NY., 1972, p. 97.
- E.W. Colvin, *Chem. Soc. Rev.*, **7**, 15 (1978).
- R. West and T.J. Barton, *J. Chem. Ed.*, **57**, 165 (1980) ; *ibid.*, **57**, 334 (1980).
- I. Fleming, *Chem. Soc. Rev.*, **16**, 83 (1981).
- E.W. Colvin, *Silicon in Organic Synthesis*, Butterworth and Co (Publishers), London 1981.
- J. Yamawaki and T. Ando, *Chem. Lett.*, 755 (1979).
- B. Rigo, C. Lespagnol and M. Pauly, *J. Heterocyclic Chem.*, submitted for publication.
- Z. Grzonka, *Rocz. Chem.*, **47**, 1401 (1973).
- R. Appel, R. Kleinstück and K. Ziehn, *Chem. Ber.*, **104**, 1030 (1971).
- M.L. Hallensleben, *Tetrahedron Lett.*, **20**, 2057 (1972).
- G. Schwarz, H. Alberts and H.R. Kricheldorf, *Liebigs Ann. Chem.*, 1257 (1981).

(Received in France 9 October 1985)